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Response Under 37 CFR 1.116  
Expedited Procedure  
Group No. 2823

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: MIURA, et al  
Serial No.: 09/977,207  
Filed: October 16, 2001  
For: SEMICONDUCTOR DEVICE AND PRODUCTION  
THEREOF  
Group: 2823  
Examiner: T. Dang

AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

December 10, 2002

Sir:

In response to the Office Action of September 10, 2002, please amend the  
above-identified application as follows:

IN THE CLAIMS

Please amend Claims 18 and 23 as follows:

C1  
18. (amended) A process for producing a semiconductor device, which comprises  
the steps of: